

Coming in lanuary

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A Design Approach for Increased Safety and Reliability

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Negotiating a Severance Package

Project Close-Out

Chemical Engineering Progress

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Letter from the Publisher



A year of change

uch about your magazine changed in the last year. The first year of the new millennium saw a new design, new editorial departments and features, an electronic reader response system and a host of less visible improvements to make *CEP* more valuable to you. Many of you wrote to comment about the changes, some to express satisfaction, some to offer constructive criticism. Not all of you agreed with all of the changes, but most of you approved of the direction *CEP* is headed.

The year 2002 will be less about change and more about expanding and refining editorial coverage of issues that are important to practicing chemical engineers. We will continue to publish the greatest number of pages of technical articles, while we broaden our focus to include features on the disciplines in which newly-graduated chemical engineers are working.

Similar to the way change has come to *CEP*, much is different today in the CPI. In January we will publish an in-depth feature on the state of the chemical engineering profession. Juxtaposing an historical reference line with interviews among chemical engineers in a wide range of jobs, we will attempt to show clearly how your profession is changing and continues to evolve. As Editor Kristine Chin mentioned in her November editorial, after reading about the breadth and depth of change taking place in your profession, a new definition of "CPI" may be appropriate.

As always, we seek your input on our stewardship of your magazine. Please let us know how we're doing.

Jane Cally

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